

**Amendments to the Claims:**

This listing of claims will replace all prior versions, and listings, of claims in the application:

**Listing of Claims:**

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1. (Currently Amended): A liquid crystal display (LCD) device comprising:  
first and second substrates assembled together with some space therebetween, at least one substrate having an etched outer surface; and  
[a passivation film] passivation layers outside the first and second substrates,  
wherein [the passivation film is] the passivation layers are formed of a material having a refractive index within about 10% difference of the refractive index of at least one of the first and second substrates, and  
wherein the passivation layers include one of BenzoCycloButene (BCB) and photo-acrylate.

2. (Original): The LCD device as claimed in claim 1, wherein at least one of the first and second substrates includes glass.

3. (Original): The LCD device as claimed in claim 1, wherein the passivation film is an organic film.

4. (Cancelled)

5. (Currently Amended): An LCD device comprising:  
first and second etched substrates;

a liquid crystal layer between the first and second etched substrates; and  
[a passivation film] passivation layers outside the first and second etched substrates,  
wherein [the passivation film is] the passivation layers are formed of a material having a  
refractive index within about 10% difference of the refractive index of at least one of the first  
and second etched substrates, and

wherein the passivation layers include one of BenzoCycloButene (BCB) and photo-  
acrylate.

6. (Original): The LCD device as claimed in claim 5, wherein at least one of the first and  
second etched substrates includes glass.

7. (Original): The LCD device as claimed in claim 5, wherein the passivation film is an organic  
film.

~~8.~~ (Cancelled)

9. (Currently Amended): A method for manufacturing an LCD device, comprising:

preparing first and second substrates;

assembling the first and second substrates;

etching a surface of at least one of the first and second substrates to form a thin substrate;

and

forming [a passivation film] passivation layers on an entire surface of the first and second  
substrates,

wherein [the passivation film is] the passivation layers are formed of a material having a

refractive index difference within about 10% of the refractive index of at least one of the first and second substrates[ is], and

wherein the passivation layers include one of BenzoCycloButene (BCB) and photo-acrylate.

10. (Original): The method as claimed in claim 9, wherein at least one of the first and second substrates includes glass.

11. (Original): The method as claimed in claim 9, wherein the passivation film is an organic film.

12. (Original): The method as claimed in claim 11, wherein the organic film is formed by a spin coating process.

13. (Cancelled)

14. (Original): The method as claimed in claim 9, further comprising injecting a liquid crystal between the first and second substrates, after forming the passivation layers on the surface of the first and second substrates.

15. (Original): The method as claimed in claim 9, further comprising injecting a liquid crystal between the first and second substrates, after assembling the first and second substrates with each other.

16. (Original): The method as claimed in claim 9, further comprising polishing the surface of the first and second substrates after etching a surface of at least one of the first and second substrates.

17. (Original): The method as claimed in claim 16, wherein polishing includes mechanically polishing the assembled substrates while spraying coolant on the assembled substrates.

18. (Original): The method as claimed in claim 17, wherein mechanically polishing includes polishing with sandpaper.

19. (Original): The method as claimed in claim 17, wherein mechanically polishing includes polishing with a polisher.

20. (Original): The method as claimed in claim 9, wherein the etching includes dipping the substrate into an etchant.

21. (Original): The method as claimed in claim 20, wherein the etchant is an HF solution.

22. (Currently Amended): The method as claimed in claim 20, wherein the etching includes etching the [glass] substrate by exothermic reaction between the [glass] substrate and the etchant.

23. (Original): The method as claimed in claim 9, wherein assembling the first and second substrates with each other includes a sealing pattern.

24. (Currently Amended): A liquid crystal display (LCD) device, comprising:

first and second substrates;

a liquid crystal layer between the first and second substrates; and

[a passivation film] passivation layers on the surfaces of the first and second substrates,

wherein [the passivation film is] the passivation layers are formed of a material in which  
a refractive index difference of the first and second glass substrates is within about 10%, and

wherein the passivation layers include one of BenzoCycloButene (BCB) and photo-  
acrylate.

25. (Original): The liquid crystal display as claimed in claim 24, wherein the substrates include  
glass.

26. (Original): The liquid crystal display as claimed in claim 25, wherein the passivation layers  
include organic material.

27. (Cancelled)

28. (Original): The liquid crystal display as claimed in claim 24, further comprising a gate  
electrode and source and drain electrodes on the first substrate.

29. (Original): The liquid crystal display as claimed in claim 25, further comprising a sealing  
pattern formed between the first and second substrates.